

**Education:**

**2001** - PhD degree in Physics, University of Valenciennes and Hainaut-Cambresis, Valenciennes, France

**Work experience:**

**01/2024 – now:** Senior scientist at Materials for Nano-systems and Biointerfaces (MNB) research group at Institute of Physics C.A.S. v.v.i.

**11/2022 – 12/2024:** CVD team lead, Quantum Brilliance, Freiburg, Germany (full-time) & Senior scientist at MNB research group at Institute of Physics C.A.S. v.v.i. (part-time)

**12/2013 – 10/2022:** Senior scientist and group leader of MNB research group at Institute of Physics C.A.S. v.v.i.

**01/2011 – 10/2013:** Researcher, LAAS-CNRS, Toulouse, France

**03/2004 – 12/2010:** Researcher, Institute for Materials Research, Hasselt, Belgium.

**04/2003 – 02/2004:** Post-doctoral researcher, Institute of Physics, Prague, Czech Republic

**07/2001 – 03/2003:** Post-doctoral researcher, Institute for Materials Research, Hasselt, Belgium

**Fields of Expertise:**

Material sciences; physics of semiconductors; vacuum technologies, physical and chemical vapor deposition methods, diamond synthesis; structural, optical and electrical characterizations; Micro-technologies; plasma characterizations.

**Research activities:**

I have been carrying out basic research at European level for more than 20 years on wide bandgap semiconductors synthesis (diamond, AlN, BN). I have a particular interest in study of thin film depositions, mostly CVD diamond, and their specific properties for their potential applications in electronics, electrochemistry, MEMS and acoustic sensors.

**Recent project managements relevant to the scope of the proposal:**

**2020-22 - GACR 20-11140S** (co-PI): “Essential Elements of Diamond Power Electronics”

**2017-19 - GACR 17-05259S:** “Electronic properties of doped diamond in high electric fields”

**2016-17 - MSMT 35785SC:** “High electric field properties of doped diamond and applications”

**2013-17 - GACR 13-31783S:** “Study of interfacial charge transfer process on boron and phosphorus doped diamond in contact with electrolyte solution”

**Academic output and selected publications relevant to the scope of the proposal:**

154+ publications in impacted journals, 2988 citations, h-index = 32 (Scopus), 3 patents, 1 book chapter.

- V. Mortet et al., “Properties of boron-doped (113) oriented homoepitaxial diamond layers” *Diam. Relat. Mater.* **111** (2021) 108223 / This article reports on the electrical and structural properties of (113) oriented epitaxial diamond layers within a broad range of boron concentration.
- N. Lambert et al. “Modeling current transport in boron-doped diamond at high electric fields including self-heating effect” *Diam. Relat. Mater.* **109** (2020) 108003 / This article discuss the origin of the super-exponential current voltage characteristic of boron-doped diamond at high electric field.
- V. Mortet et al, “Insight into boron-doped diamond Raman spectra characteristic features”, *Carbon* **115** (2017) 279 / This article is the first of a series that revise the analysis of boron-doped diamond Raman spectrum.
- V. Mortet et al. “Particularities of high electric filed conduction in p-type diamond” *App. Phys. Lett.* **108** (2016) 045005 / This article reports on the S-shape current voltage characteristic and the breakdown voltage at high electric field of boron-doped diamond.
- J. Pernot et al. “Hall hole mobility in boron-doped homoepitaxial diamond” *Phys. Rev. B* **81** (2010) 205203 / This article reports on the experiemental and theoretical study of the Hall hole mobility in boron-doped diamond in the case of low and high boron concentrations.